

In situ XAFS Analysis of Supported Pt Catalysts During Partial Oxidation of Methane

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1 Introduction

Catalytic partial oxidation of methane with a molecular oxygen under mild conditions is an extremely difficult reaction. Although it has been investigated for decades, a practical process has not been developed yet. Recently we have found that it is possible to activate oxygen atoms in an oxygen molecule homogeneously and use it as an oxidant to convert methane to dimethyl ether (DME) under ambient pressure at around 300°C over supported Pt catalysts [1]. Catalytic performance varies with the kind of support. Pt/Y₂O₃ produced solely DME at temperatures from 275°C to 375°C, whereas over Pt/TiO₂, the main oxygenate product changed from DME (275°C - 325°C) to formaldehyde (325°C - 375°C). In order to elucidate the reaction mechanism, in situ XAFS analysis was conducted and the active structure was compared between Pt/Y₂O₃ and Pt/TiO₂.

2 Experiment

The Pt catalysts were synthesized by an incipient wetness impregnation method. The concentration of Pt was 2 wt% of Pt. After the impregnation, the sample was dried and calcined at 400 °C. In situ measurements of Pt L_{III}-edge XAFS were conducted at BL-9C equipped with a Si(111) double crystal monochromator in a transmittance mode with ionizing chambers (15%Ar + 85%N₂ for I₀ and 50%Ar+50%N₂ for I). A pelletized sample was set in a gas flow cell developed by the PF-XAFS group [2]. A gas flow rate controlling system (Fujikin Co., Ltd.) was used to change the composition of the reaction gas mixture.

3 Results and discussion

Fig.1 shows the first peak (the white line) area of the normalized Pt L_{III}-edge XANES spectra under various conditions observed for Pt/TiO₂ and Pt/Y₂O₃. The peak height is thought to reflect the oxidation state of Pt.

For the calcined Pt/TiO₂, judging from the intensity of the white line ($\mu_t = 2.4$), the electronic state of Pt was in an almost fully oxidized state (Pt⁴⁺), whereas the oxidation state of Pt in Pt/Y₂O₃ was a little lower compared to Pt in Pt/TiO₂, since the intensity of the white line was weaker ($\mu_t = 2.1$).

The catalysts was activated by reduction at 400°C. Pt in Pt/TiO₂ was deeply reduced to Pt⁰ ($\mu_t = 1.3$), but Pt in Pt/Y₂O₃ was not reduced to Pt⁰ ($\mu_t = 1.5$).

After the reduction, various reaction gas mixtures were introduced to the catalyst. For Pt/TiO₂, when the gas mixture changed between oxidative (CH₄+NO+O₂ or NO+O₂) and reductive (CH₄) conditions, corresponding

changes in the white line intensity were observed, indicating the oxidation state of Pt fluctuated between Pt⁰ and Pt²⁺ (estimated from the white line intensity). On the contrary, for Pt in Pt/Y₂O₃, when the reaction gas mixture was introduced to the catalyst, Pt was oxidized to the Pt²⁺ state. After that, the electronic state of Pt remained in Pt²⁺ regardless of the conditions. In other words, it was found that the Pt²⁺ state was significantly stabilized in Pt/Y₂O₃, which might be the reason for high selectivity to DME.

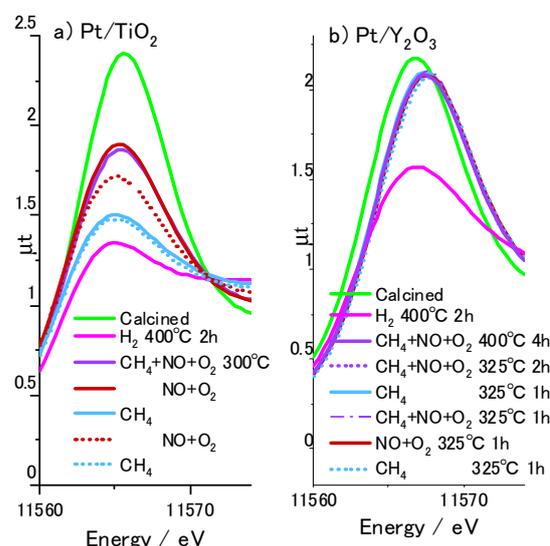


Fig.1 In situ Pt L_{III}-edge XAFS spectra for Pt/TiO₂ and Pt/Y₂O₃. The conditions are as follows: CH₄+NO+O₂ indicates CH₄:NO:O₂:He =20:1:1:78, NO+O₂ indicates NO:O₂:He =:1:1:98, and CH₄ indicates CH₄:He =20:80.

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References

- [1] V. Vargheese, J. Murakami, K. K. Bando, I. T. Ghampson, G.-N. Yun, Y. Kobayashi, S. T. Oyama, *J. Catal.*, **389** (2020) 352–365.
- [2] M. Kimura, K. Uemura, T. Nagai, Y. Niwa, Y. Inada, M. Nomura, *J. Phys.: Conference Series* **190** (2009) 012163.

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